

Coating Capability of Photopatterning

The Ewha ADL team has 3 spin coaters and can experiment with wafers ranging from piece-scale wafers up to 6-inch scale wafers.

	# of Owned	Substrate Size	Spin Speed	Bowl Size	# of Recipe	Bowl Material
 SPIN-120T	2	Piece~4 inch (Glass, Si Wafer)	300 ~ 7,000 rpm(@without load) an error of less than 3 % (overseas 10,000 rpm)	8 inch	50 steps 50 Recipes	polypropylene
 SPIN-3000BD	1	4 inch~6 inch (Glass, Si Wafer)	300 ~ 7,000 rpm(@without load) an error of less than 3 %	12 inch	50 steps 50 Recipes	Stainless steel